

TCAD simulation II

E. Giulio Villani

Overview

- **Simulation example of 2D PN junction using SDEVICE**
- **IV and CV**

TCAD simulation SDEVICE

TCAD Synopsys Simulation

- **Sentaurus Device** is a numeric semiconductor device simulator, capable of simulating the electrical, thermal, and optical characteristics of various semiconductor devices.
- It simulates 1D, 2D, and 3D device behaviour over a wide range of operating conditions, including mixed-mode circuit simulation, combining numerically simulated devices with their compact modeling, which is performed on a SPICE-based circuit simulation level.



1 **File Section:** input/output files

2 **Electrode Section:** electrode definition, matching those in the input grid

3 **Physics Section:** physics models to use in the simulation

4 **Plot Section:** variables to plot

5 **Math Section:** solvers

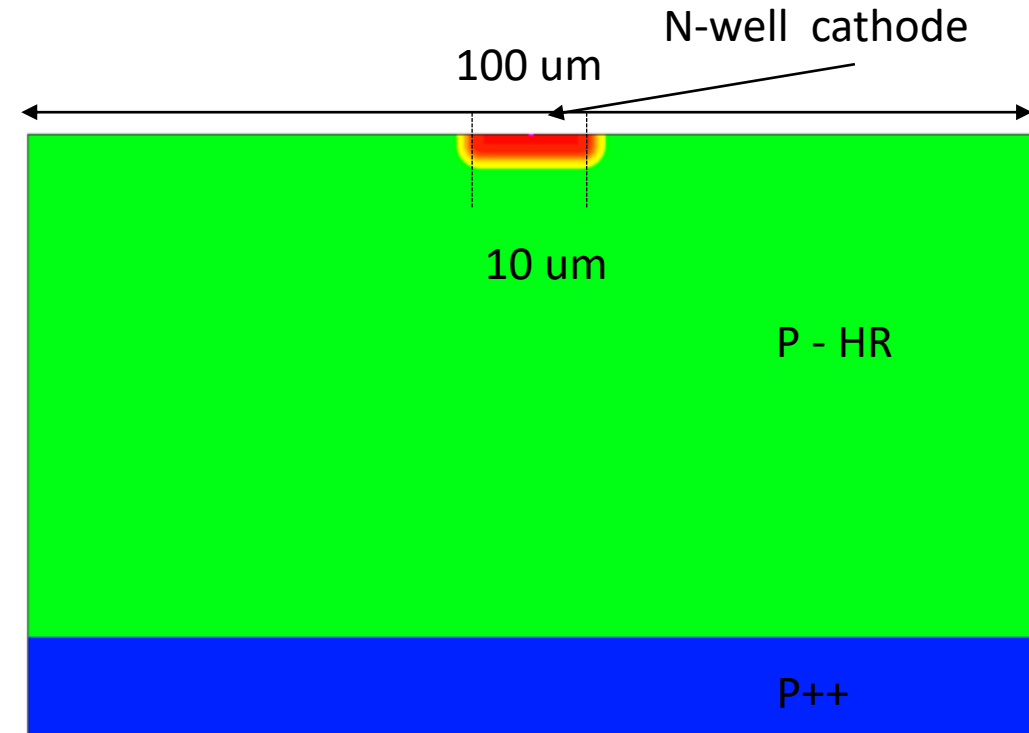
6 **Solve Section:** what to solve (IV,CV, Charge injection)

A typical command file of Sentaurus Device consists of several sections (or statement blocks), with each section executing a relatively independent function. The default extension of the command file is `_des.cmd`, for example, `pp1_des.cmd`. To start: **sdevice**

TCAD Synopsys Simulation

- SDEVICE simulation of 2D pn junction
 - IV
 - SC/Depletion region visualisation
 - Breakdown voltage
- The DC analysis is performed by sweeping the voltage across the cathode, keeping the substrate contact grounded

				
TwoDsde	sdeviceIV_REV	deviceIV_FWL	deviceCV_RE	sdeviceCCE
	Temp			Vbias
	[n2] 280	[n6] --	[n9] --	[n15] --
				[n12] 100



TCAD Synopsys Simulation

- SDEVICE command file:
 - **File Section:** input/output files
 - **Electrode Section:** electrode definition, matching those in the input grid

```
#####      2D PN junction DC bias analysis #####

#define Vdd 1000.

## Input and Output Files

        File {

        grid    = "2D_PNjct_msh.tdr"

        }

### Electrode definition

        Electrode {

##$ By default Ohmic contact
        { Name="cathode" Voltage= 0.0  }

        { Name="substrate" Voltage= 0.0  }

        }
```

TCAD Synopsys Simulation

- SDEVICE command file
 - **Physics Section:** physics models to use in the simulation
 - **Plot Section:** variables to plot

Physics models

Physics {

Fermi

Temperature = @Temp@

Mobility(

DopingDep

PhuMob Enormal (Lombardi PosInterfaceCharge)

HighFieldSaturation(GradQuasiFermi)

)

Recombination(

SRH(DopingDep TempDependence ElectricField

(Lifetime = Hurkx))

Auger

Avalanche(Okuto EParallel BandgapDependence)

##Avalanche(Unibo EParallel BandgapDependence)

)

EffectiveIntrinsicDensity(BandGapNarrowing

(OldSlotboom))

}

Plots definition

Plot

{

eDensity hDensity

TotalCurrent/Vector eCurrent/Vector hCurrent/Vector

eMobility hMobility....

}

TCAD Synopsys Simulation

- SDEVICE command file
- **Math Section:** solvers to use

Math definition

```
Math {  
  
    BreakCriteria{ Current(Contact="cathode" AbsVal=1e-6) }  
  
    extrapolate  
    digits= 4  
    ##ExtendedPrecision  
    numberOfThreads= maximum  
    Derivatives  
    Avalderivatives  
    RelErrControl  
  
    method=blocked  
    submethod=pardiso(iterativeRefinement)  
  
    Iterations=20  
    Rhsmin      = 1e-20  
    ParallelToInterfaceInBoundaryLayer(FullLayer -ExternalBoundary)  
        GeometricDistances  
        eMobilityAveraging=ElementEdge  
        hMobilityAveraging=ElementEdge  
    ##AvalDensGradQF  
        ErrRef(electron)=1e8  
        ErrRef(hole)=1e8  
        RefDens_eParallel_ElectricField_HFS= 1e17  
        RefDens_hParallel_ElectricField_HFS= 1e17  
        RefDens_eParallel_ElectricField_Aval= 1e17  
        RefDens_hParallel_ElectricField_Aval= 1e17  
}
```

TCAD Synopsys Simulation

- SDEVICE command file
 - **Solve Section:** what to solve (IV,CV, Charge injection...)

Solve procedure

Solve {

```
Coupled(Iterations= 500 LineSearchDamping= 1e-4){ Poisson }  
Coupled(Iterations= 50 LineSearchDamping= 1e-4){ Poisson Electron Hole }  
Plot (FilePrefix = "2D_PNjct_Temp@Temp@_bias_0V")
```

```
NewCurrentPrefix="2D_PNjct_Temp@Temp@_RIV"
```

```
Quasistationary (  
    InitialStep=0.001 Increment=2.0 decrement=4.0  
    MaxStep=0.05 Minstep=1.e-15  
Goal { name="cathode" Voltage= Vdd}  
    ) { Coupled { Poisson Electron
```

```
Hole }
```

```
Plot(FilePrefix="2D_PNjct_Temp@Temp@_RBias_" Time=(0.1;0.2;0.3;0.4;0.5)  
NoOverWrite)
```

```
### fixed plot interval
```

```
###
```

```
CurrentPlot( Time=(Range=(0 1) Intervals= 200
```

```
) )
```

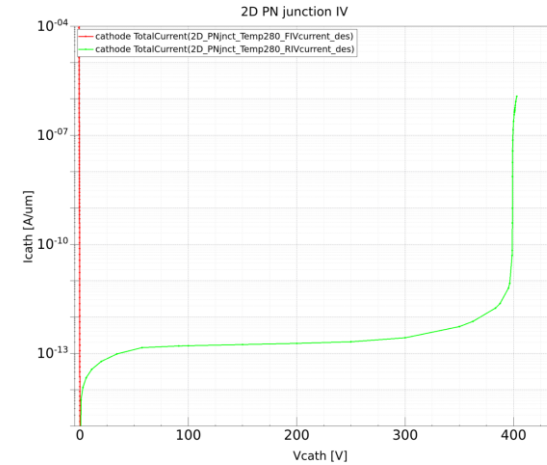
```
}
```

```
}
```

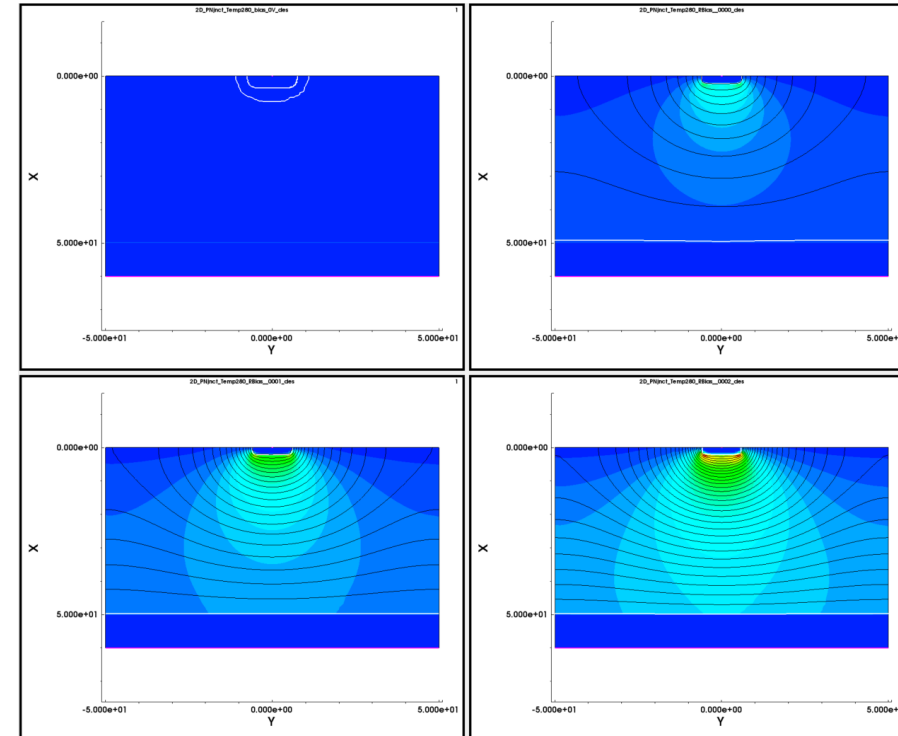
TCAD Synopsys Simulation

- Visualize the resulting mesh using **SVISUAL**
 - Re-mesh the structure changing the p – doping
 - Visualise the meshing Investigate the extension of depletion vs. bias/doping/temperature

$$w = \sqrt{\frac{2\epsilon_s(N_A + N_D)}{e(N_A N_D)} (V_{bi} - V)}$$



FWD and REV IV @ 280 K vs. Vbias



Depletion and x-Field vs. Vbias

Thank you

giulio.villani@stfc.ac.uk

- Simulation example : 2D pn using SDEVICE
- IV (FWD/REV), SC, Depletion region